

Article 5: Fire Protection and Prevention

Division 27: Semiconductor Fabrication Facilities

*(“Hazardous Materials-General Provisions” added 4-8-2008 by O-19728 N.S.)
(Retitled to “Semiconductor Fabrication Facilities” on 4-6-2016
by O-20625 N.S.; effective 5-6-2016.)*

§55.2701: Semiconductor Fabrication Facilities

2701.1 Scope through 2705.3.4.1 Identification. Sections 2701.1 through 2705.3.4.1 of the California Fire Code have been adopted without changed pursuant to section 55.0101(a).

*(“Hazardous Materials-General Provisions” added 4-8-2008 by O-19728 N.S.;
effective 5-8-2008.)
(Amended 7-31-2012 by O-20188 N.S.; effective 8-30-2012.)
(Retitled to “Semiconductor Fabrication Facilities” and amended 4-6-2016 by
O-20625 N.S.; effective 5-6-2016.)*